

# POWER AMERICA

Draft Public Roadmap  
May 2016

## Vision

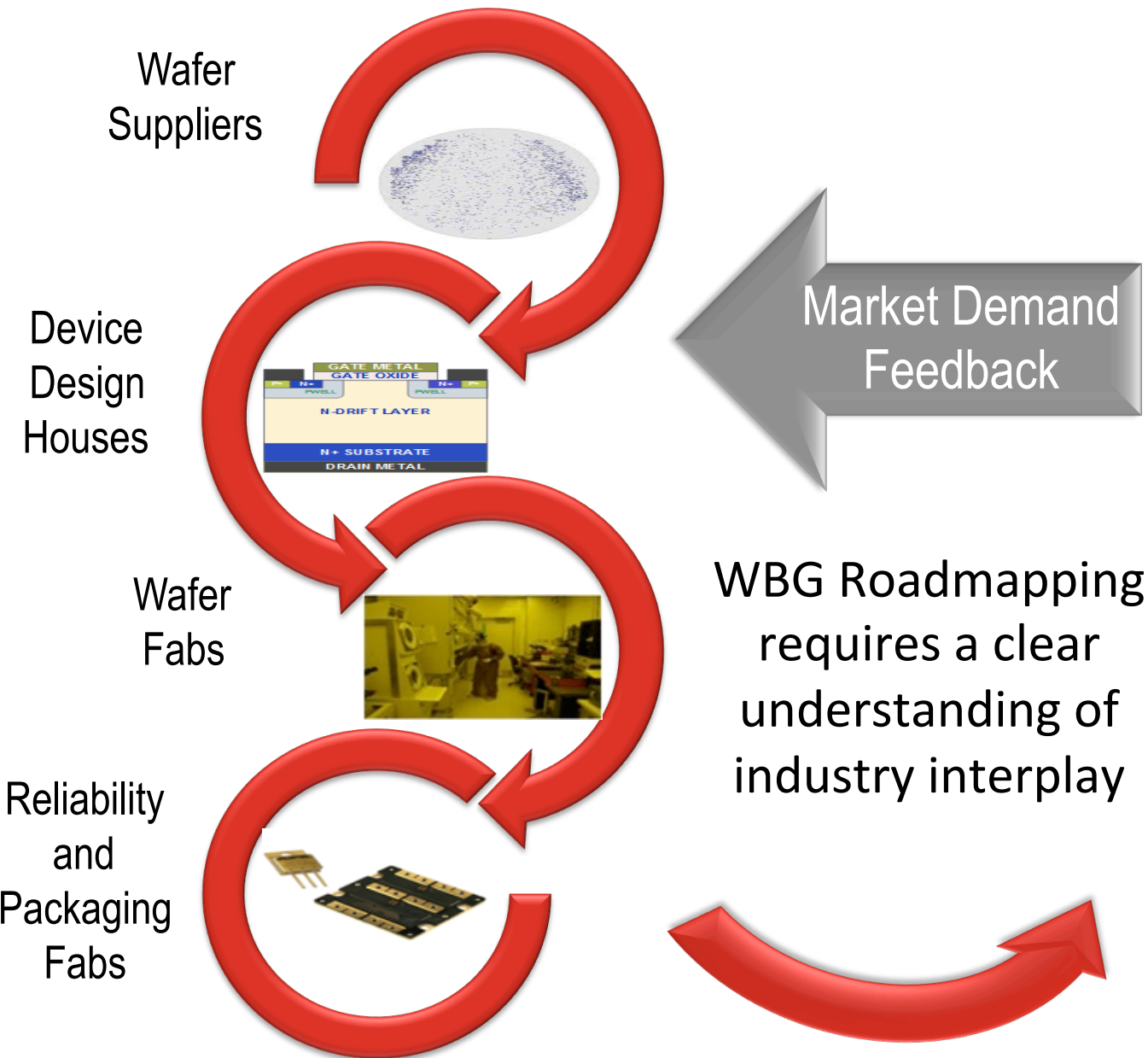
**Accelerate Wide Adoption of WBG Semiconductor Devices in PE Systems**

## Strategy

- Highlight Performance Advantages of WBG Devices
  - Stress high voltage at low resistance, high temperature, and high frequency WBG device operational advantages over those of *Si* counterparts
- Establish Reliability of WBG Devices
  - Leverage *Si* Reliability best practices in developing WBG reliability standards
- Showcase System Insertion Advantages of WBG Devices
  - Develop packaging technology that allows for full WBG performance potential
  - Demonstrate WBG PE system value proposition in terms of higher efficiency, and smaller weight/volume at low overall additional system cost
- Reduce Cost of WBG Devices
  - Leverage mature *Si* fabrication practices, and qualify WBG specific processes to enable multiple source high-yield volume production
- Train Workforce in WBG devices/modules/systems

## Benefits

Job Creation, Accelerated Technology Innovation, Energy Savings, Smaller Environmental footprint

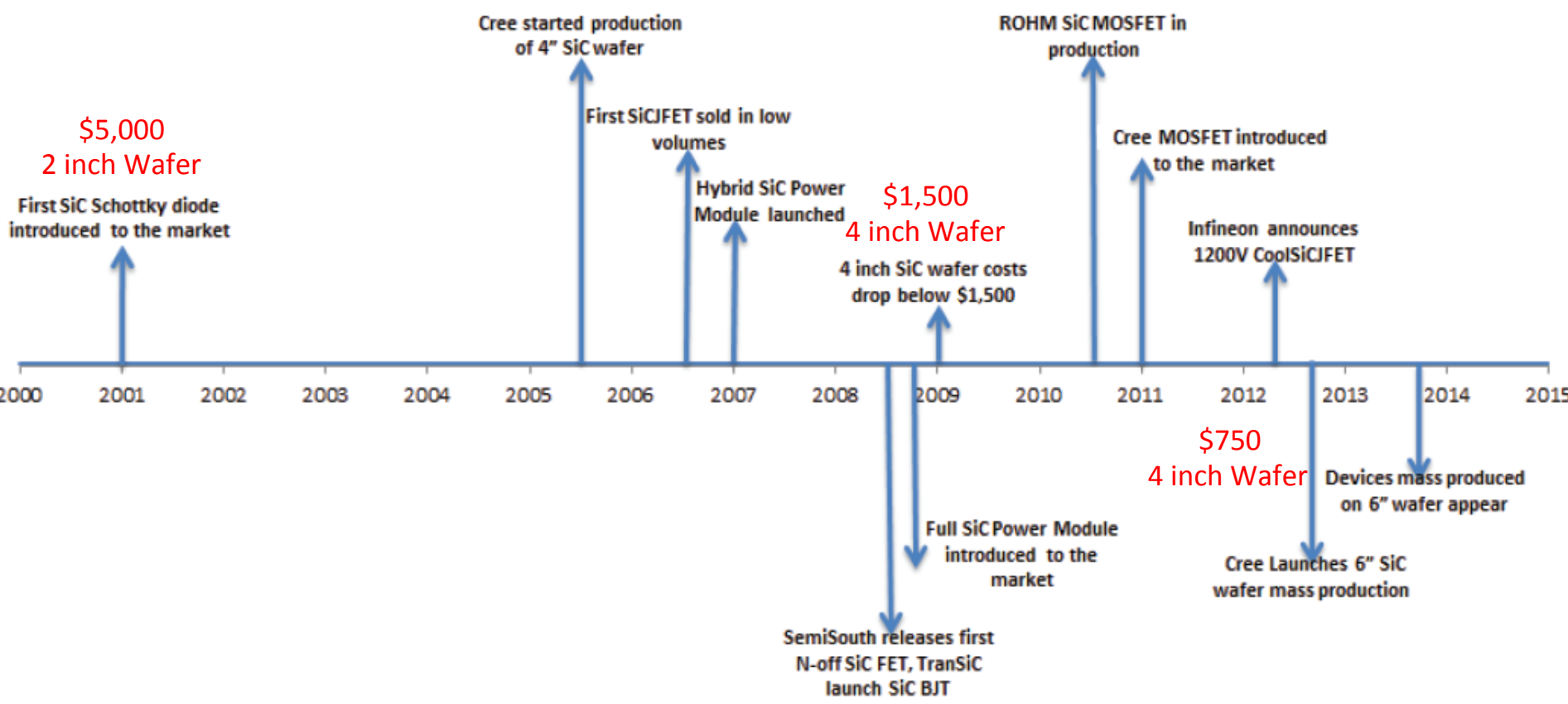


WBG Roadmapping requires a clear understanding of industry interplay

### OEMs

Images illustrating various industries served by WBG: Power Electronics, Data Centers, Automotive, Renewable Energy (Solar and Wind).

Credit: IHS Technology (<http://technology.ihs.com>): *The World Market for Silicon Carbide & Gallium Nitride Power Semiconductors* - 2013 Edition

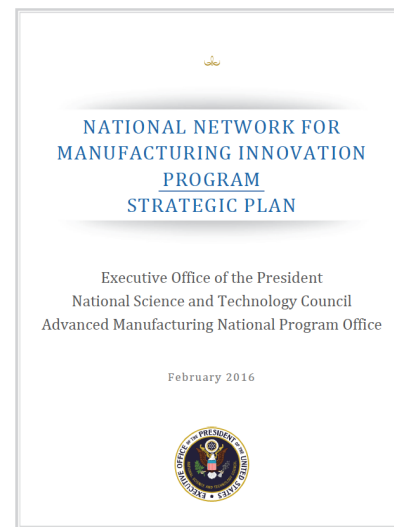


Manufacturing volume lowers wafer costs. Larger area wafer lowers device cost.

\*Modified from DOE Quadrennial Technology Review Ch 6N

## • Strategic Government Policy Documents

- Quadrennial Energy Review (QER)
- Quadrennial Technology Review (QTR)-CH 6N.
- Advanced Manufacturing Partnership 2.0
  - (NEC / PCAST 2014/ OSTP 2014)
- Quadrennial Defense Review (QDR)
  - Naval S&T Strategic Plan
  - Army S&T Campaign Plans 2015-2035
  - DOD Energy and Power Roadmap (2015)



### EERE Vision

A strong and prosperous America powered by clean, affordable, and secure energy

## • WBG Power Semiconductor Roadmaps

- USDRIVE, Electrical and Electronics Technical Team Roadmap, June 2013
- ARPA-e, *A Pathway to Commercialization of Wide Bandgap Semiconductors in Power Electronics*, March 2015
- PEIC, *Driving Collaboration for Power Electronics Technology Roadmapping Review*, Nov. 2015
- PSMA, Power Technology Roadmap Trends 2014-2019, 2015
- ETH – ECPE Roadmap, *Vision – Power Electronics 2025*, 2015

## • Market Driven Roadmaps

- *GaN and SiC Devices for Power Electronics Applications*, August 2015
- *GaN and SiC and WBG Materials for Power Electronics Applications*, October 2015
- *GaN Devices for Power Electronics – Patent Investigation*, 2015
- *Wide Band Gap Power Electronics: A Path Toward CO2 Emission Decrease*, Yole presentation at Semicon West Conference, July 2014
- *Market and Technology Trends in WBG Materials for Power Electronics Applications*, Yole presentation at the CS MANTECH Conference, May 2015
- PEIC, NEXTEnergy, *Strengthening the Domestic Power Electronics Ecosystem*, Report on the Domestic Supply Chain Gaps in the Power Electronics Industry, April 2015
- Point-the-Gap, *GaN & SiC Technology & Market Knowledge Update*, 2015
- Ampere Laboratory, INSA de Lyon, *Wide Bandgap Power Devices GaN and SiC*, March 2015

**Driving  
Cost**

1. Complete X-Fab investment to provide ability to run process without outsourcing steps.
2. Facilitate Introduction of companies to Foundry Model.
- 3. Develop PowerAmerica Fabrication Process.**
4. Continue support of vertical integration with packaging.

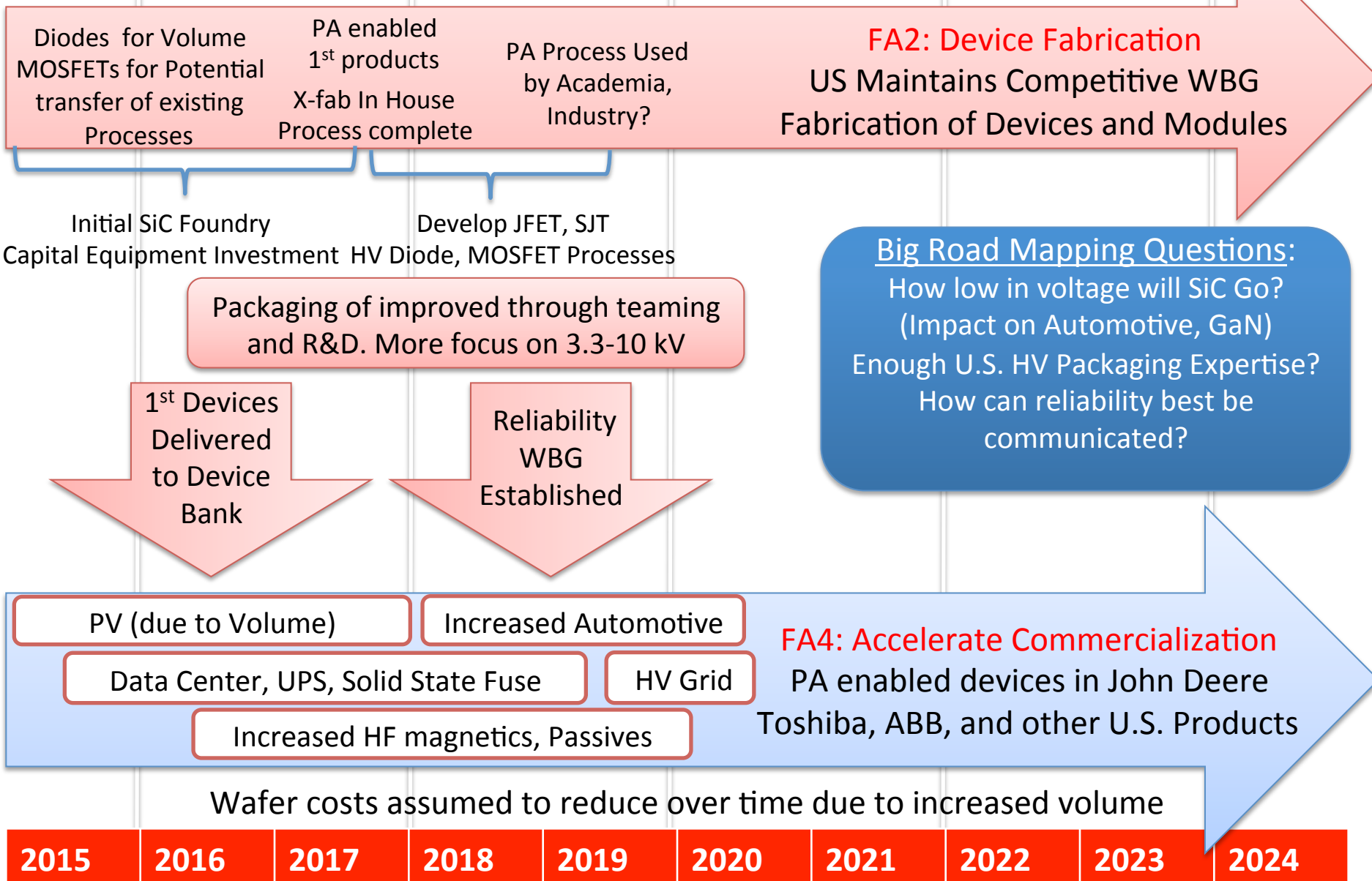
**Driving  
Reliability**

1. Establish connections with PELs working group for SiC devices.
2. Establish connections with Texas Instruments, Infineon about JEDEC.
- 3. Develop Independent Reliability Center.**

**Accelerating  
Commercialization**

1. Showcase System Insertion Advantages of WBG Devices.
2. Train workforce.
- 3. Establish device bank to reduce lead time and improve accessibility.**

# SiC Strategic planning





# GaN Strategic Planning

Triquint/RFMD Merger.  
Tranphorm Fab. Japan  
Navitas @TSMC

GaN Foundry in US could  
Be important Second source,  
Allow GaN Innovation.

**FA2: Device Fabrication GaN**  
US Maintains Competitiveness In Design,  
I.P. and GaN Innovation

GaN Projects to US manufacturing  
Applications

Will Vertical GaN be Ready?  
When 8 inch GaN/Si?

Improved Packaging, Improved P.E.  
Manufacturing Methods (Fred Lee)

1<sup>st</sup> Devices  
Delivered  
to Device  
Bank

Reliability  
WBG  
Established

Big Road Mapping Questions:  
Timing of GaN Market Growth?  
What Voltage will power GaN Excel?  
Importance of Gate Drive Integration?  
How to Leverage RF foundries?

PV (due to Volume)

Increased Automotive?

**FA4: Accelerate Commercialization**

Data Centers, Consumer Elect. Adapters, Wireless Power

PA enabled GaN Applications  
Manufactured in US.

Increased HF magnetics, Passives

Wafer costs assumed to reduce over time due to increased volume

|      |      |      |      |      |      |      |      |      |      |
|------|------|------|------|------|------|------|------|------|------|
| 2015 | 2016 | 2017 | 2018 | 2019 | 2020 | 2021 | 2022 | 2023 | 2024 |
|------|------|------|------|------|------|------|------|------|------|

# POWERAMERICA Silicon Carbide Roadmap Drives Long Term Strategy

|                        | 2015                               | 2016                         | 2017                   | 2018                    | 2019                    | 2020                       | 2021                   | 2022                   | 2023                   | 2024                        |
|------------------------|------------------------------------|------------------------------|------------------------|-------------------------|-------------------------|----------------------------|------------------------|------------------------|------------------------|-----------------------------|
| I                      | AEC-Q101 qual high- $I_{DS}$ chips | 175°C is $T_{Jmax}$ for qual | 650V – 175A chip @ 90C | 1.2kV – 150A chip @ 90C | 1.7kV – 125A chip @ 90C | 2.4kV – 100A chip @ 90C    | 3.3kV – 50A chip @ 90C | 4.5kV – 40A chip @ 90C | 6.5kV – 30A chip @ 90C | 6.5kV – 60A IGBT chip @ 90C |
| V                      | 1.2, 1.7 kV SBD/FET                | 3.3 kV SBD/FET               | 2.4kV SBD/FET          | 4.5, 6.5 kV SBD/FET     | 6.5, 10 kV SBD/FET      | 6.5kV SBD/IGBT             | 10 kV PiN Diode/IGBT   | 15 kV PiN Diode/IGBT   | 20 kV PiN Diode/IGBT   | 30 kV PiN Diode/IGBT        |
| \$                     | 1.2 kV FET 40 c/A                  | 1.2 kV FET 30 c/A            | 1.2 kV FET 25 c/A      | 1.2 kV FET 20 c/A       | 1.2 kV FET 15 c/A       | 1.2 kV FET                 | 1.2 kV FET             | 1.2 kV FET             | 1.2 kV FET             | 1.2 kV FET                  |
| App                    | PFC, PV 5-10 kW                    | Power Supply                 | UPS/HVAC/SSCB          | PV 50-250kW, 1.5kV bus  | EV Traction             | MV VSD Automotive Chargers | Central PV 1-10 MW     | DC dis. Data Servers   | Wind                   | Grid power Flow             |
| Frequency / Technology |                                    |                              |                        |                         |                         |                            |                        |                        |                        |                             |
|                        | 40-100kHz LF DMOS                  | 50-500kHz HF DMOS            | 40-100kHz HF trench    | 5-10kHz LF trench       | 10-30kHz LF/HF trench   | 5-10kHz LF IGBT            | 5-10kHz LF IGBT        | 0.1-1.0MHz HF IGBT     | 5-10kHz LF IGBT        | 5-10kHz LF IGBT             |

## Enablers:

Packaging for low thermal impedance, +200°C, and low stray inductance  
 Soft Magnetics  
 Gate driver design

Device design services  
 Open access foundry services  
 Workforce training  
 Device bank to be introduced Fall 2016

# POWERAMERICA Gallium Nitride Roadmap Drives Long Term Strategy

| 2015                           | 2016          | 2017          | 2018                            | 2019 | 2020            | 2021                              | 2022                    | 2023       | 2024 |
|--------------------------------|---------------|---------------|---------------------------------|------|-----------------|-----------------------------------|-------------------------|------------|------|
| SiC & Si Substrates            |               |               |                                 |      |                 | GaN Substrates & Vertical Devices |                         |            |      |
| <200 V HFET                    | 650 V HFET    | 900 V HFET    |                                 |      |                 | 900V SBD, 900 V JFET              | 1.2 kV SBD, 1.2 kV JFET | 10 kV JFET |      |
| SiC & Si substrates            | Si substrates |               |                                 |      |                 | GaN substrates                    |                         |            |      |
| RF/wireless,* DC/DC converters | PV converters | PV converters | Envelope Tracking, Wireless Pwr | PFC  | EV/HEV Chargers | PFC, EV/HEV Charger               |                         |            |      |

## Challenges:

Not clear when GaN Market will mature.

GaN community needs to unite for 2<sup>nd</sup> source foundry capacity.

SiC moving into GaN voltage space.

## Opportunities:

GaN is increasing in voltage and reliability.

GaN Gate Driver Integration

GaN at lower voltages beats silicon in size and performance.